INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)				Docket Number (Optional) YPL-0073 Application Number 10/765,366						
4.5	INTO	RMATION DISCLOSURE (Use several sheets if necess	E CITATION ary)		Applicant(s) Sun-hee Kim, et al.					
APR 1.5 2004 E (Use several sheets if necessary)				Filing Date Group Art Unit			NYA			
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AB		"Chip PCR. I. Surface Georgi E. Hvichia, La 1996; Pgs. 375-379	e passivation of m irry J. Kricka and	icrofabrica d Peter Wil	ted silicon-glass chips ding; Nucleic Acids Re	for PCR"; Autho esearch, Vol. 24, N	rs: Manu A. S No. 2; Oxford	shoffner, Ji University I	ng Cheng, Press;	
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EXAMINE	R.	/Angela Bertagna	a/		DATE CONSIDERED 09/26/2006					
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_)		Docket Number (Optional)	Application Number			
	ORMATION DISCLOSURE CITATION	YPL-0073 Applicant(s)	10/765,366			
INFO	(Use several sheets if necessary)	Sun-hee Kim, et al.				
		Filing Date 1-27-2004	Group Art Unit NYA			
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not considered. Include copy of this form with next communication to applicant.

					Docket Number (Optional) YPL-0073		Application Number 10/765,366			
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